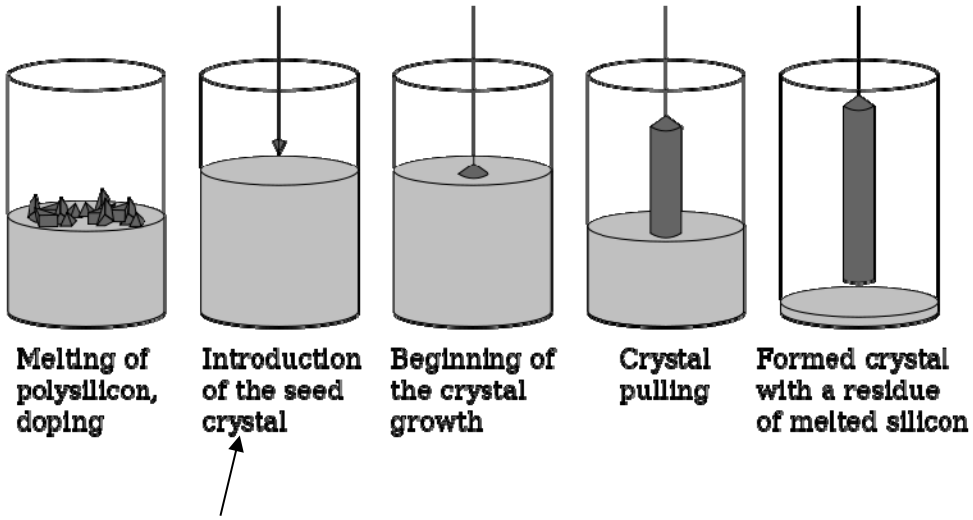
4. Extrinsic semiconductors / Carrier Transport

Oct. 23, 2019

Crystal growth

Czochralski Process



add dopants to the melt

images from wikipedia

Crystal growth

Float zone Process

Neutron transmutation

$^{30}Si + n \rightarrow {}^{31}Si + \gamma$

$^{31}Si \rightarrow {}^{31}P + \beta$

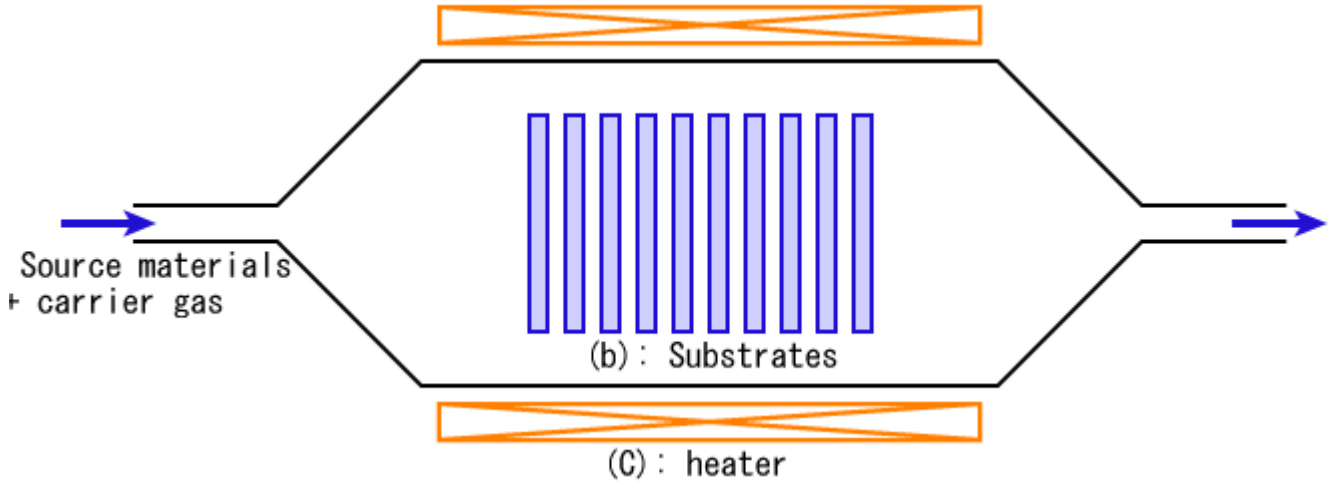
image from wikipedia

Gas phase diffusion

AsH_3 (Arsine) or PH_3 (phosphine) for n-doping
B_2H_6 (diborane) for p-doping.

http://www.microfab.de/foundry/services/diffusion/index.html

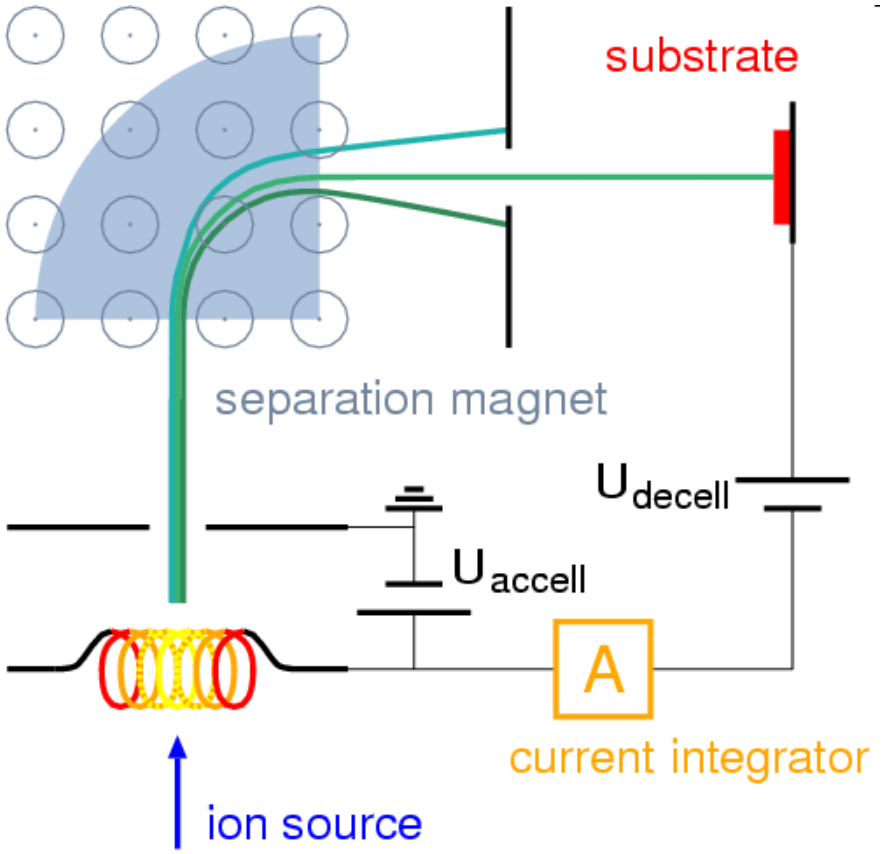
Chemical vapor deposition



Epitaxial silicon CVD SiH_4 (silane) or SiH_2Cl_2 (dichlorosilane)
PH_3 (phosphine) for n-doping or B_2H_6 (diborane) for p-doping.

image from wikipedia

Ion implantation

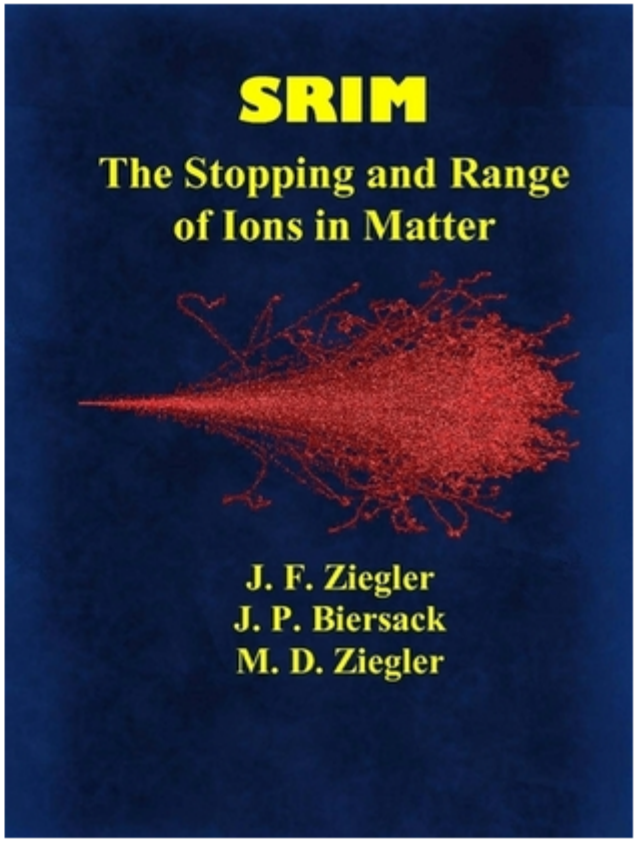


Implant at 7º to avoid channeling

SRIM

The Stopping and Range of Ions in Matter

James F. Ziegler, Jochen P. Biersack, Matthias D. Ziegler



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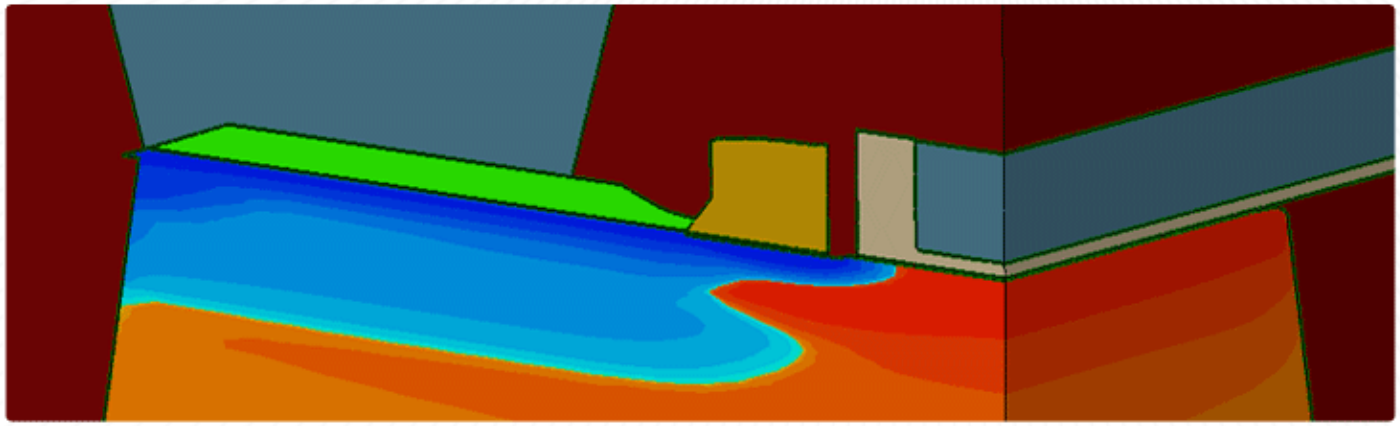
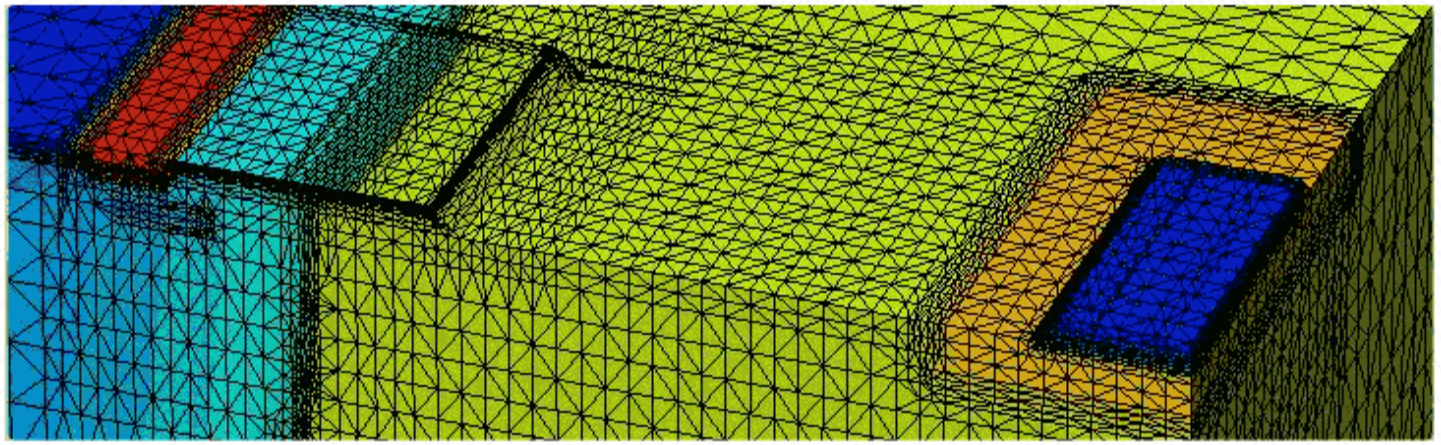
Process Simulation



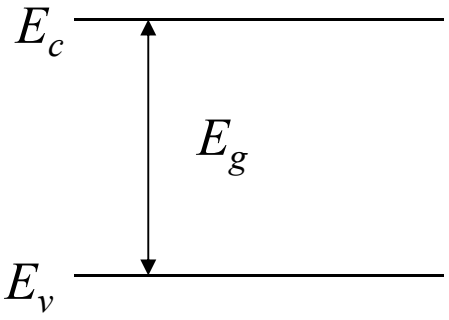
Device Simulation



http://www.synopsys.com

Review

$$n = N_c \exp\left(\frac{E_F - E_c}{k_B T}\right)$$



$$p = N_v \exp\left(\frac{E_v - E_F}{k_B T}\right)$$

Intrinsic semiconductors

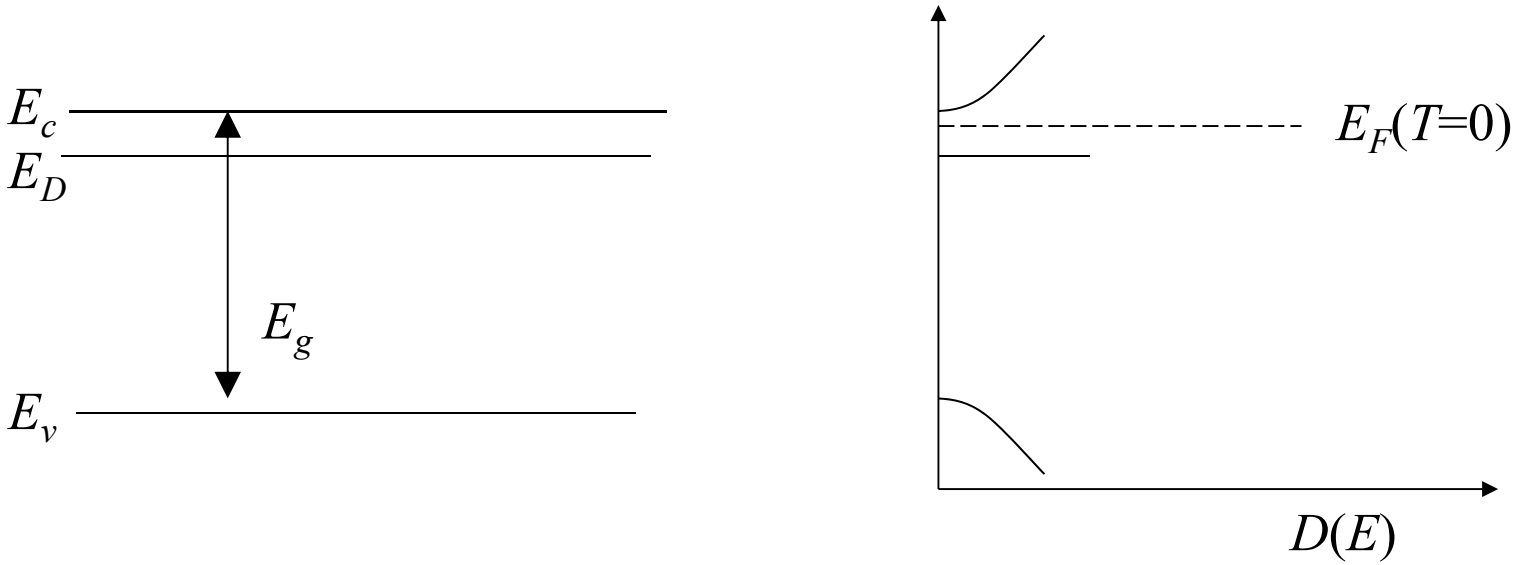
$$n = p = n_i = \sqrt{N_c N_v} \exp\left(\frac{-E_g}{2k_B T}\right)$$

$$E_F = \frac{E_c + E_v}{2} + \frac{k_B T}{2} \ln\left(\frac{N_v}{N_c}\right)$$

Donors

Five valence electrons: P, As

States are added in the band gap just below the conduction band



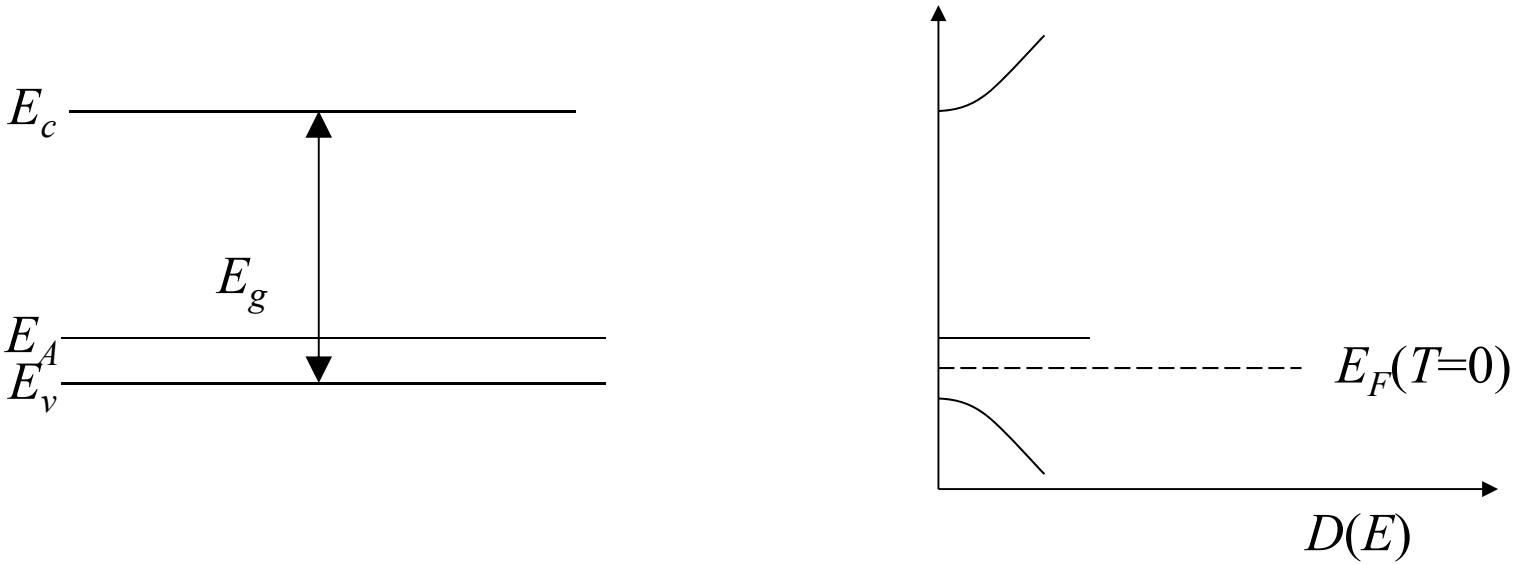
n-type: $n \sim N_D$ Many more electrons in the conduction band than holes in the valence band.

majority carriers: electrons; minority carriers: holes

Acceptors

Three valence electrons: B, Al, Ga

States are added in the band gap just above the valence band



p-type: $p \sim N_A$ Many more holes in the valence band than electrons in the conduction band.

majority carriers: holes; minority carriers: electrons

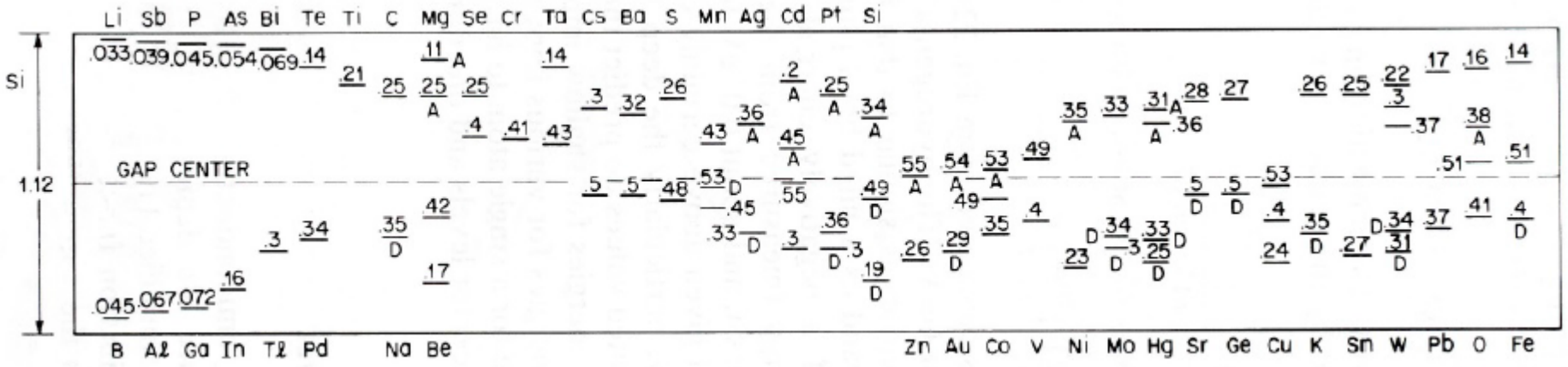
Donor and Acceptor Energies

Semiconductor	Donor	Energy (meV)
Si	Li	33
	Sb	39
	P	45
	As	54
Ge	Li	9.3
	Sb	9.6
	P	12
	As	13
GaAs	Si	5.8
	Ge	6.0
	S	6.0
	Sn	6.0

Energy below the conduction band

Semiconductor	Acceptor	Energy (meV)
Si	B	45
	Al	67
	Ga	72
	In	160
Ge	B	10
	Al	10
	Ga	11
	In	11
GaAs	C	26
	Be	28
	Mg	28
	Si	35

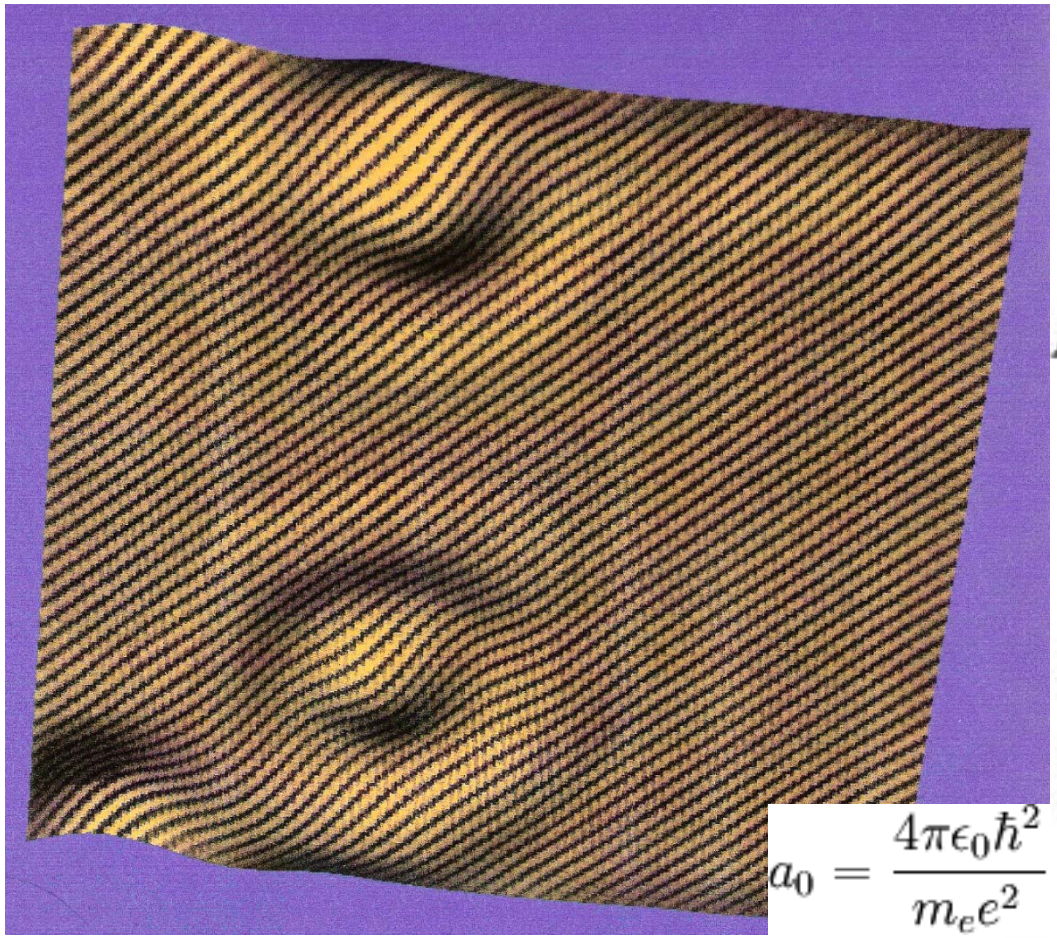
Energy above the valence band



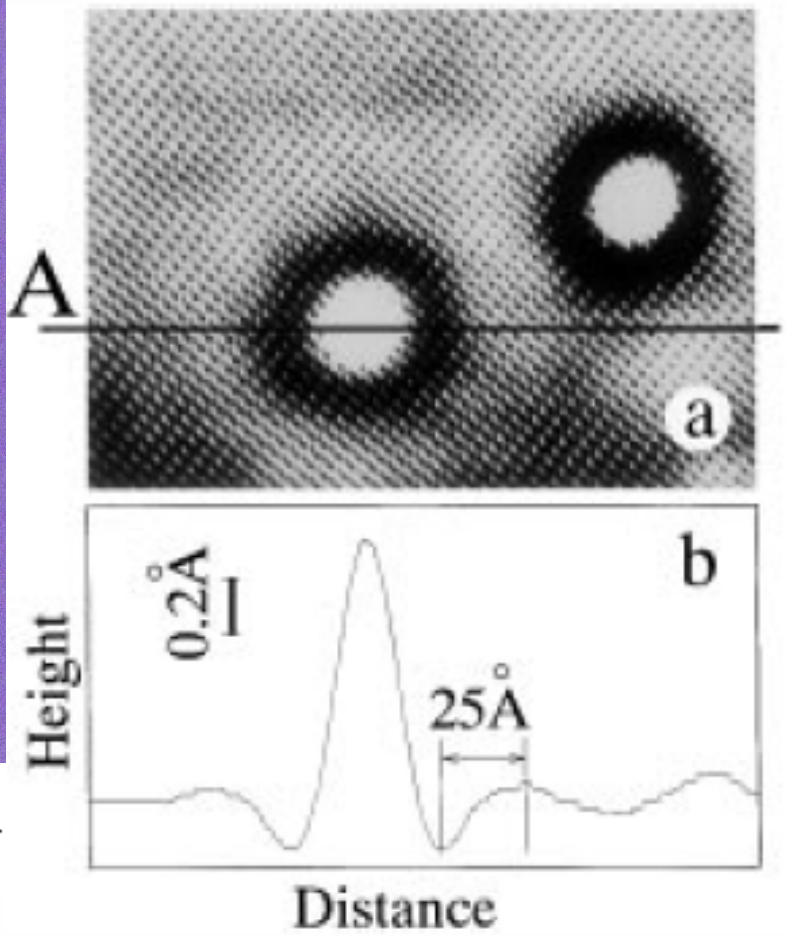
Source: Semiconductor Devices Physics and Technology, S.M. Sze, 1985

Direct Observation of Friedel Oscillations around Incorporated Si_{Ga} Dopants in GaAs by Low-Temperature Scanning Tunneling Microscopy

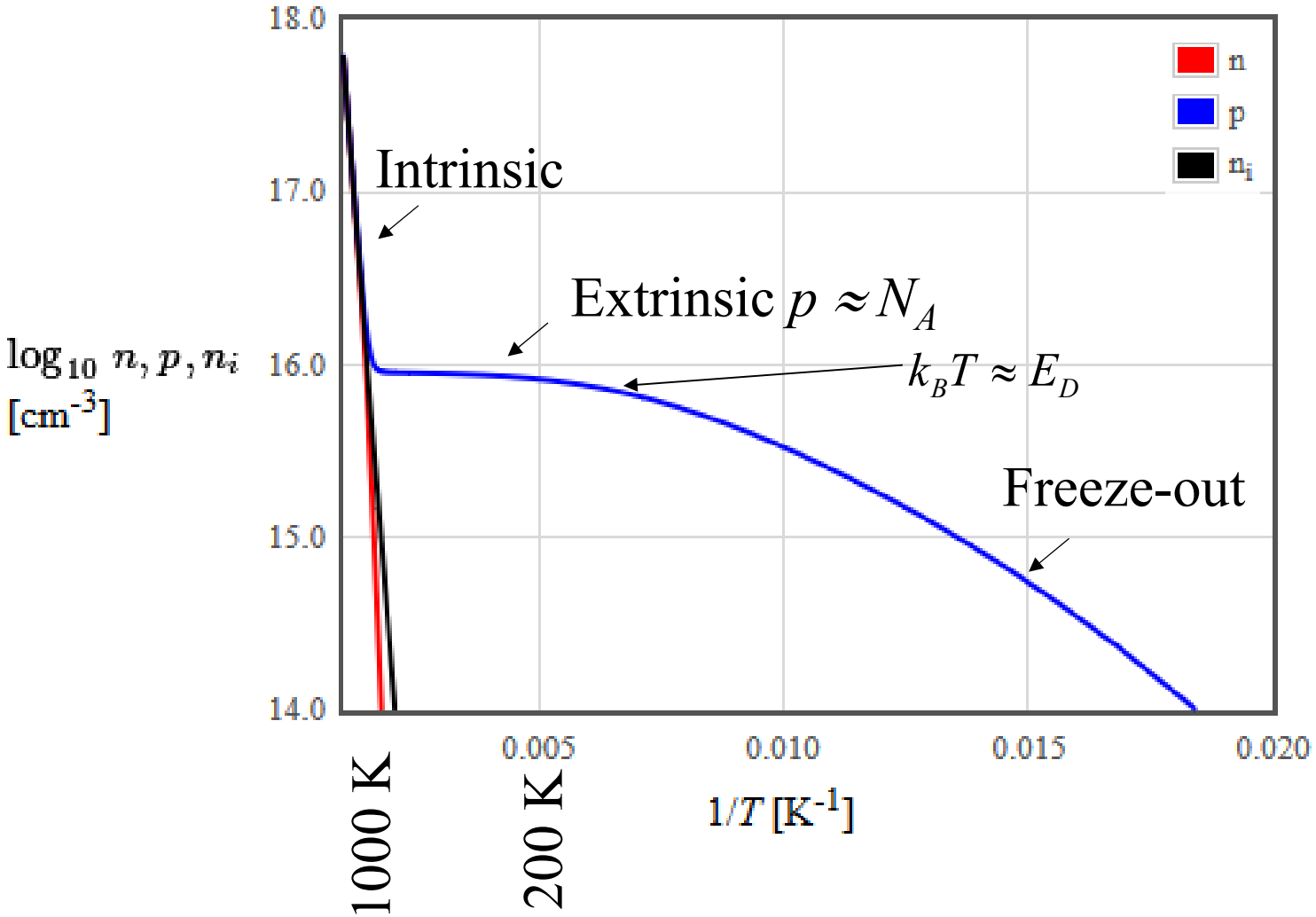
M. C. M. M. van der Wielen, A. J. A. van Roij, and H. van Kempen
Research Institute for Materials, University of Nijmegen, Toernooiveld 1, 6525 ED Nijmegen, The Netherlands
(Received 25 July 1995)



$$a_0 = \frac{4\pi\epsilon_0\hbar^2}{m_e e^2}$$



Temperature dependence



Temperature dependent conductivity

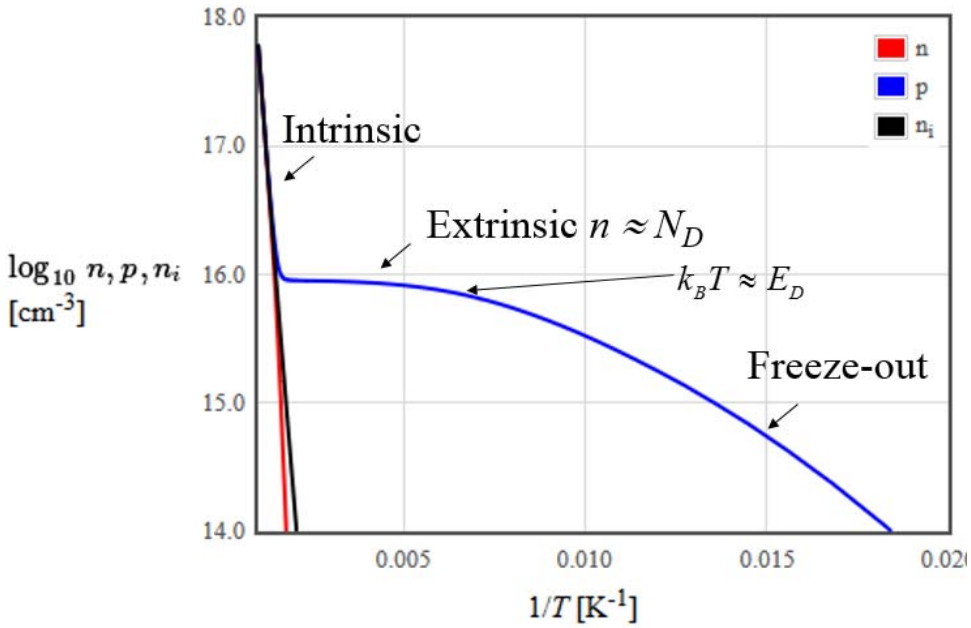
A doped semiconductor makes a transition from extrinsic behavior to intrinsic behavior when number of thermally activated charge carriers equals the number of dopants. What is this temperature for silicon doped with boron at 4E+17 cm^{-3}?

E_g is slightly temperature dependent but use $E_g = 1.12$ eV, $N_c = 2.78 \times 10^{25}$ m^{-3} and $N_v = 9.84 \times 10^{24}$ m^{-3} to estimate the transition temperature.

$T =$ [ ] K

Submit answer | Clear

$$n_i = \sqrt{N_v N_c \exp\left(-\frac{E_g}{k_B T}\right)}$$



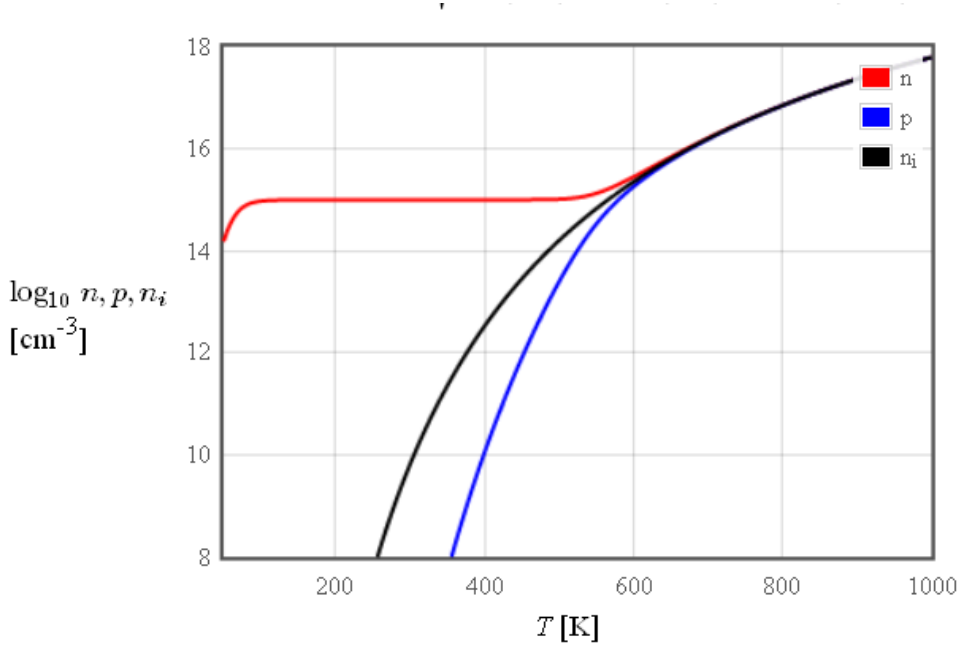
n-type

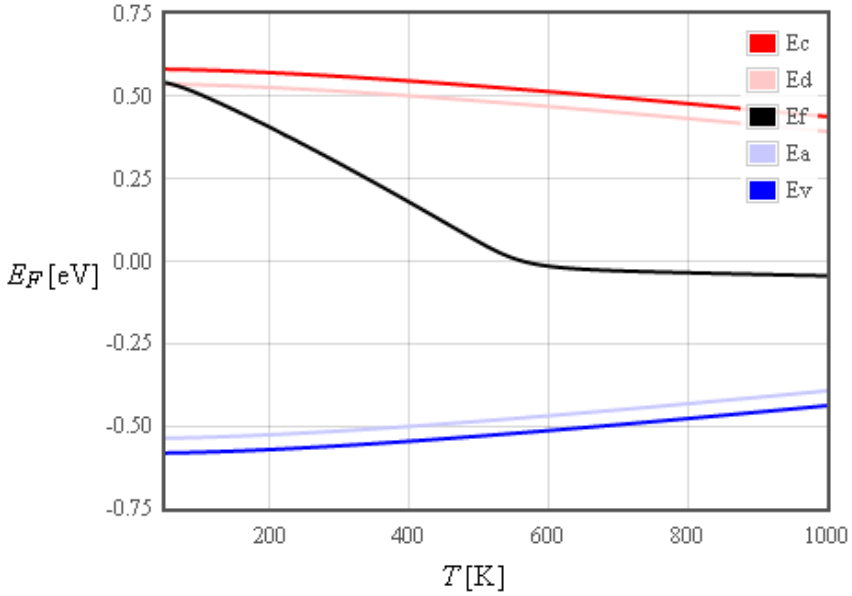
n-type $N_D > N_A$, $p \sim 0$

$$n = N_D = N_c \exp\left(\frac{E_F - E_c}{k_B T}\right)$$

$$E_F = E_c - k_B T \ln\left(\frac{N_c}{N_D}\right)$$

For n-type, $n \sim$ density of donors,
$p = n_i^2 / n$





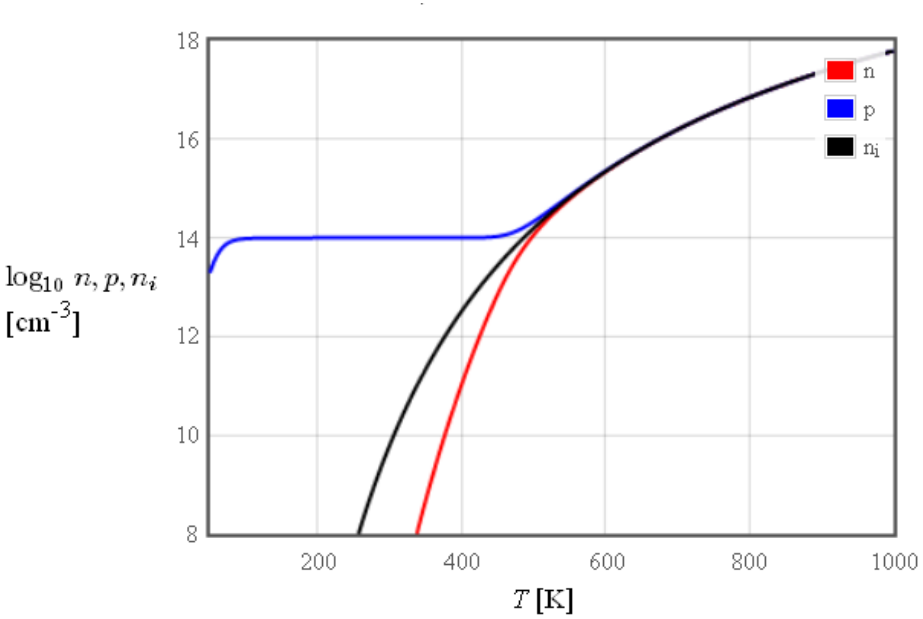
p-type

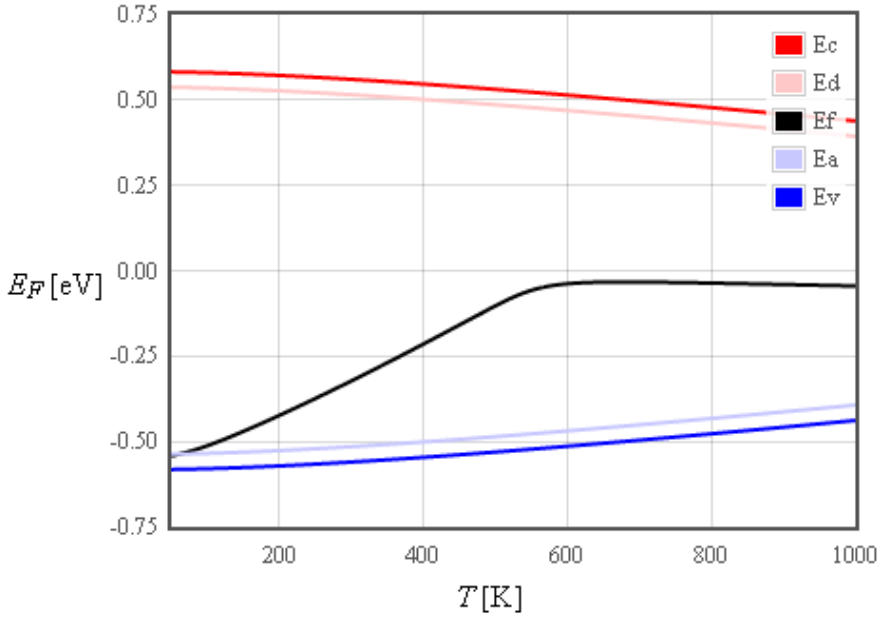
p-type $N_A > N_D$, $n \sim 0$

$$p = N_A = N_v \exp\left(\frac{E_v - E_F}{k_B T}\right)$$

$$E_F = E_v + k_B T \ln\left(\frac{N_v}{N_A}\right)$$

For p-type, $p \sim$ density of acceptors,
$n = n_i^2/p$





Intrinsic / Extrinsic

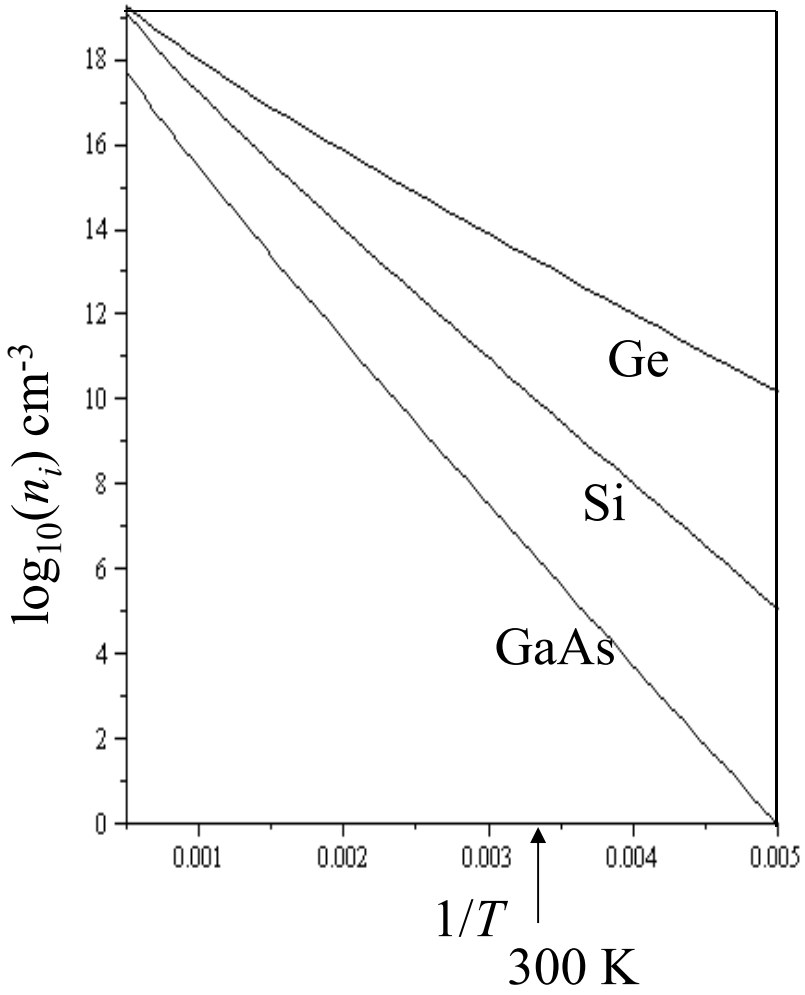
Intrinsic: $n = p$

Conductivity strongly temperature dependent near room temperature

Extrinsic: $n \neq p$

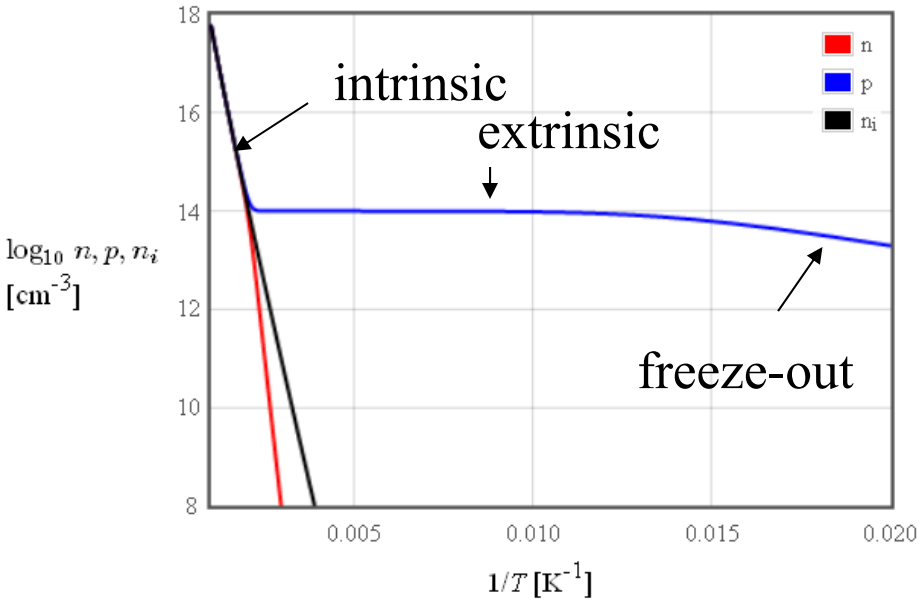
Conductivity almost temperature independent at room temperature

Intrinsic semiconductors



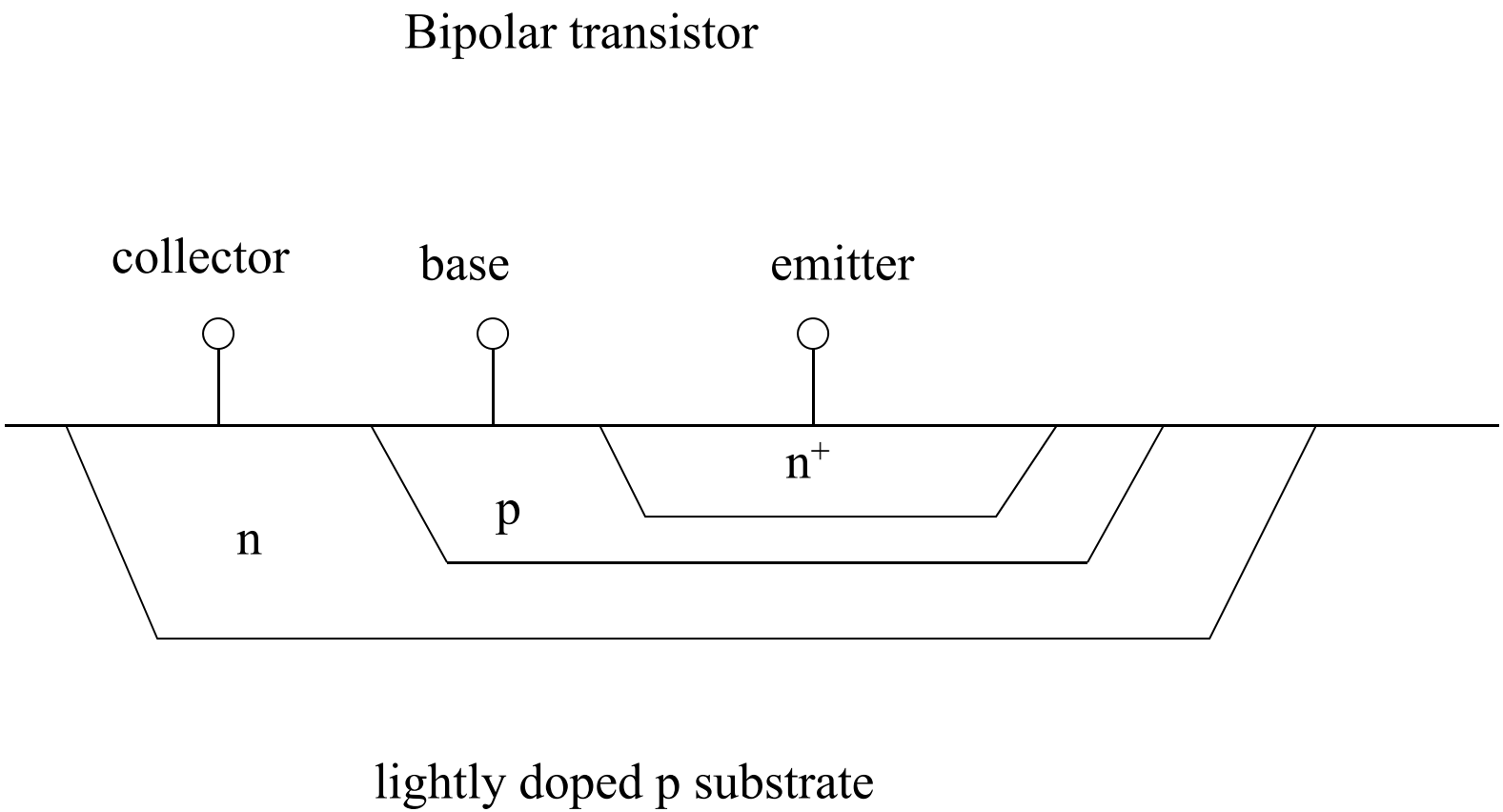
$$n_i = \sqrt{N_v N_c}\exp\left(-\frac{E_g}{2k_B T}\right)$$

Extrinsic semiconductors

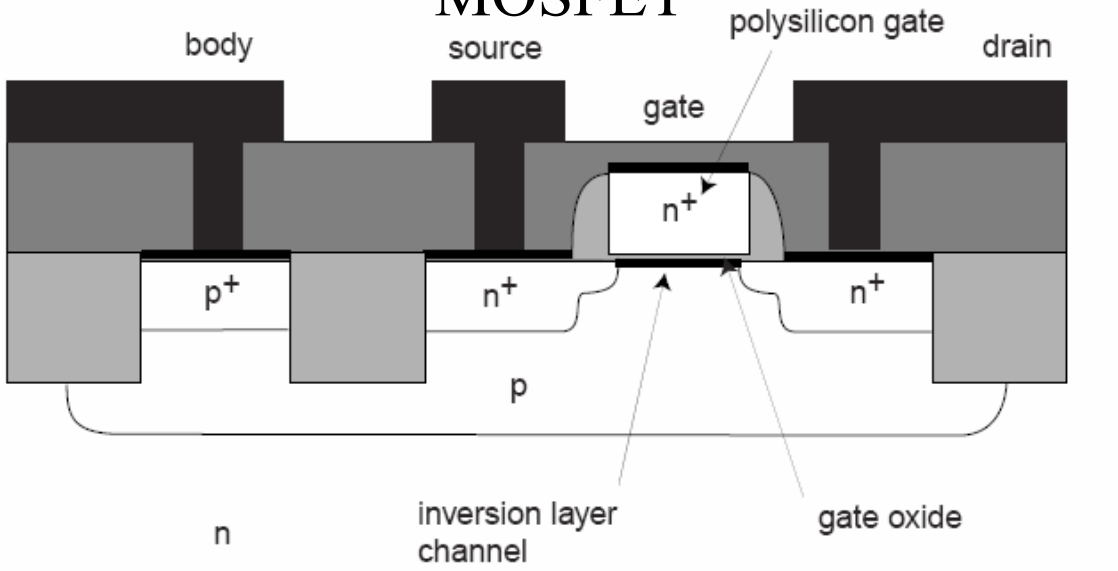


At high temperatures, extrinsic semiconductors have the same temperature dependence as intrinsic semiconductors.

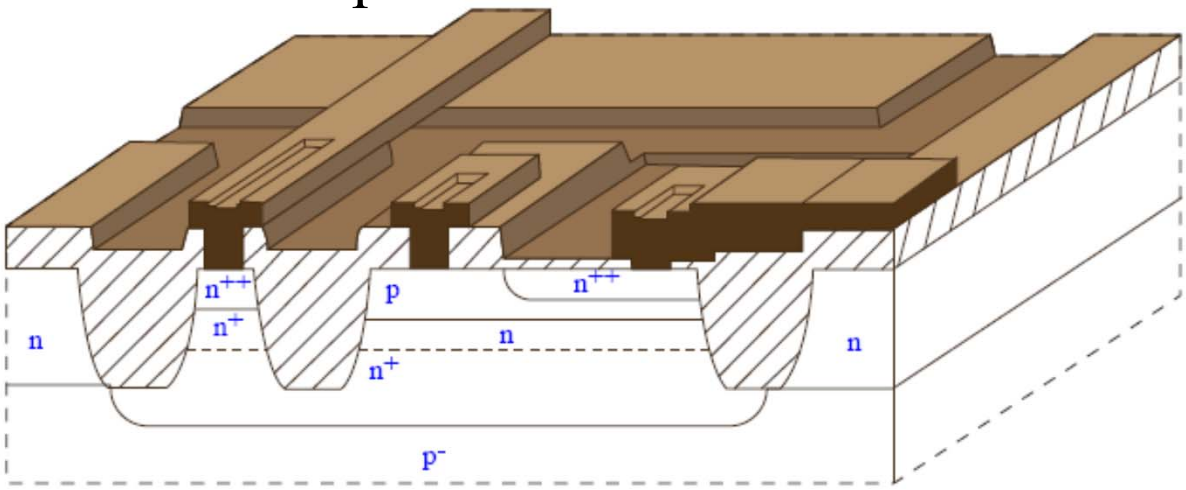
Why dope with donors AND acceptors?



MOSFET



Bipolar Junction Transistor



Oxide isolated integrated BJT - a modern process

Ionized donors and acceptors

For $E_v + 3k_BT < E_F < E_c - 3k_BT$ Boltzmann approximation

$$N_D^+ = \frac{N_D}{1 + 2\exp\left(\frac{E_F - E_D}{k_BT}\right)}$$

$$N_A^- = \frac{N_A}{1 + 4\exp\left(\frac{E_A - E_F}{k_BT}\right)}$$

4 for materials with light holes and heavy holes (Si)
2 otherwise

N_D = donor density cm^{-3} N_D^+ = ionized donor density cm^{-3}

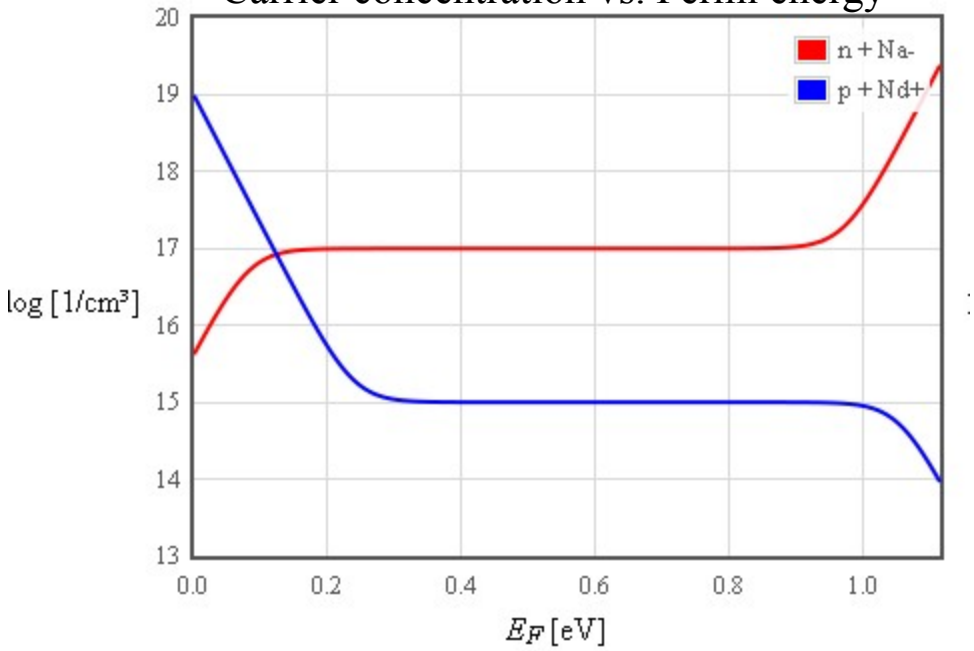
N_A = donor density cm^{-3} N_A^- = ionized donor density cm^{-3}

Mostly, $N_D^+ = N_D$ and $N_A^- = N_A$

Charge neutrality

$$n + N_A^- = p + N_D^+$$

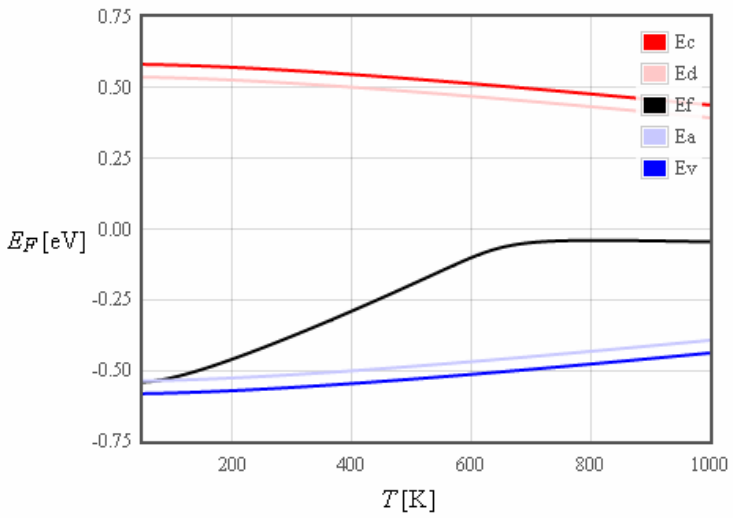
Carrier concentration vs. Fermi energy




```
for ($i=0; $i<500; $i++) {
  $Ef = $i*$Eg/500;
  $n=$Nc*pow($T/300,1.5)*exp(1.6022E-19*($Ef-$Eg)/(1.38E-23*$T));
  $p=$Nv*pow($T/300,1.5)*exp(1.6022E-19*(-$Ef)/(1.38E-23*$T));
  $Namin = $Na/(1+4*exp(1.6022E-19*($Ea-$Ef)/(1.38E-23*$T)));
  $Ndplus = $Nd/(1+2*exp(1.6022E-19*($Ef-$Ed)/(1.38E-23*$T)));
}
```

E_f	n	p	N_d^+	N_a^-	$\log(n+N_a^-)$	$\log(p+N_d^+)$
0	4.16629283405	9.84E+18	1E+15	4.19743393218E+15	15.622983869	18.9930392318
0.00224	4.54358211887	9.0229075682E+18	1E+15	4.56020949614E+15	15.6589847946	18.9553946382
0.00448	4.95503779816	8.27366473417E+18	1E+15	4.95271809535E+15	15.694843609	18.9177504064
0.00672	5.40375389699	7.58663741327E+18	1E+15	5.37710747619E+15	15.7305487171	18.8801065693

Calculating $E_F(T)$ numerically



N_c(300 K) =	2.78E19	1/cm³	Semiconductor: Si Ge GaAs
N_v(300 K) =	9.84E18	1/cm³	
E_g =	1.166-4.73E-4*T*T/(T+636)	eV	
N_d =	1E15	1/cm³	Donor: P in Si, P in Ge, Si in GaAs
E_c - E_d =	0.045	eV	
N_a =	1E16	1/cm³	Acceptor: B in Si, B in Ge, Si in GaAs
E_a - E_v =	0.045	eV	
T_1 =	50	K	
T_2 =	1000	K	

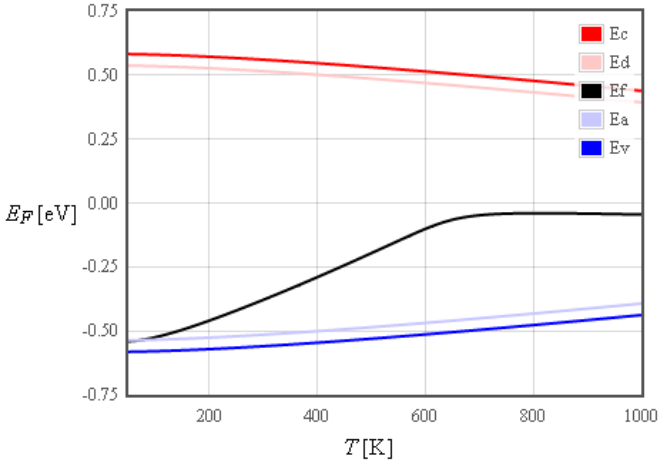
Replot

Source code

E_f	n	p	N_d^+	N_a^-	T
0.0421442489848	2.40151024146E-36	1.42005993475E+16	1E+15	1.52148150693E+16	100
0.0432605499091	3.55188567934E-34	1.60496732529E+16	1E+15	1.70727565871E+16	104
0.0443992886238	3.6447725184E-32	1.79708501904E+16	1E+15	1.89867455992E+16	108
0.0455696761919	2.70091324524E-30	1.99342913907E+16	1E+15	2.0961617146E+16	112
0.046759290261	1.49291303432E-28	2.19530074854E+16	1E+15	2.29663635196E+16	116
0.0479826534344	6.34683409239E-27	2.39841986132E+16	1E+15	2.50167521691E+16	120
0.0492194372194	2.12451662366E-25	2.60634467518E+16	1E+15	2.70669670674E+16	124
0.0504951208621	5.73929239594E-24	2.81194143968E+16	1E+15	2.91550921724E+16	128

Fermi energy vs. temperature

Fermi energy of an extrinsic semiconductor is plotted as a function of temperature. At each temperature the Fermi energy was calculated by requiring that charge neutrality be satisfied.



$N_c(300\ \mathrm{K}) =$	2.78E19	1/cm³
$N_v(300\ \mathrm{K}) =$	9.84E18	1/cm³
$E_g =$	1.166-4.73E-4*T*T/(T+636)	eV
$N_d =$	1E15	1/cm³
$E_c - E_d =$	0.045	eV
$N_a =$	1E16	1/cm³
$E_a - E_v =$	0.045	eV
$T_1 =$	50	K
$T_2 =$	1000	K

Replot

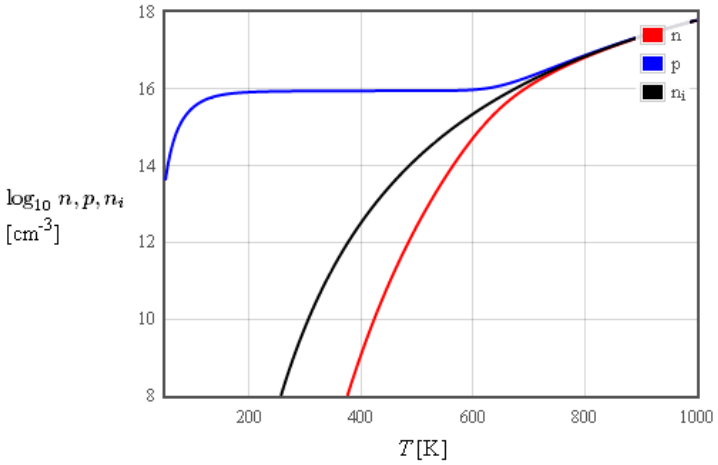
Semiconductor: Si | Ge | GaAs

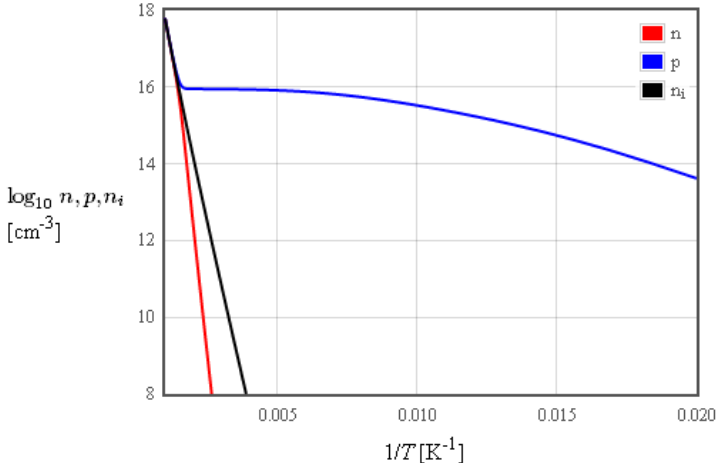
Donor: P in Si | P in Ge | Si in GaAs

Acceptor: B in Si | B in Ge | Si in GaAs

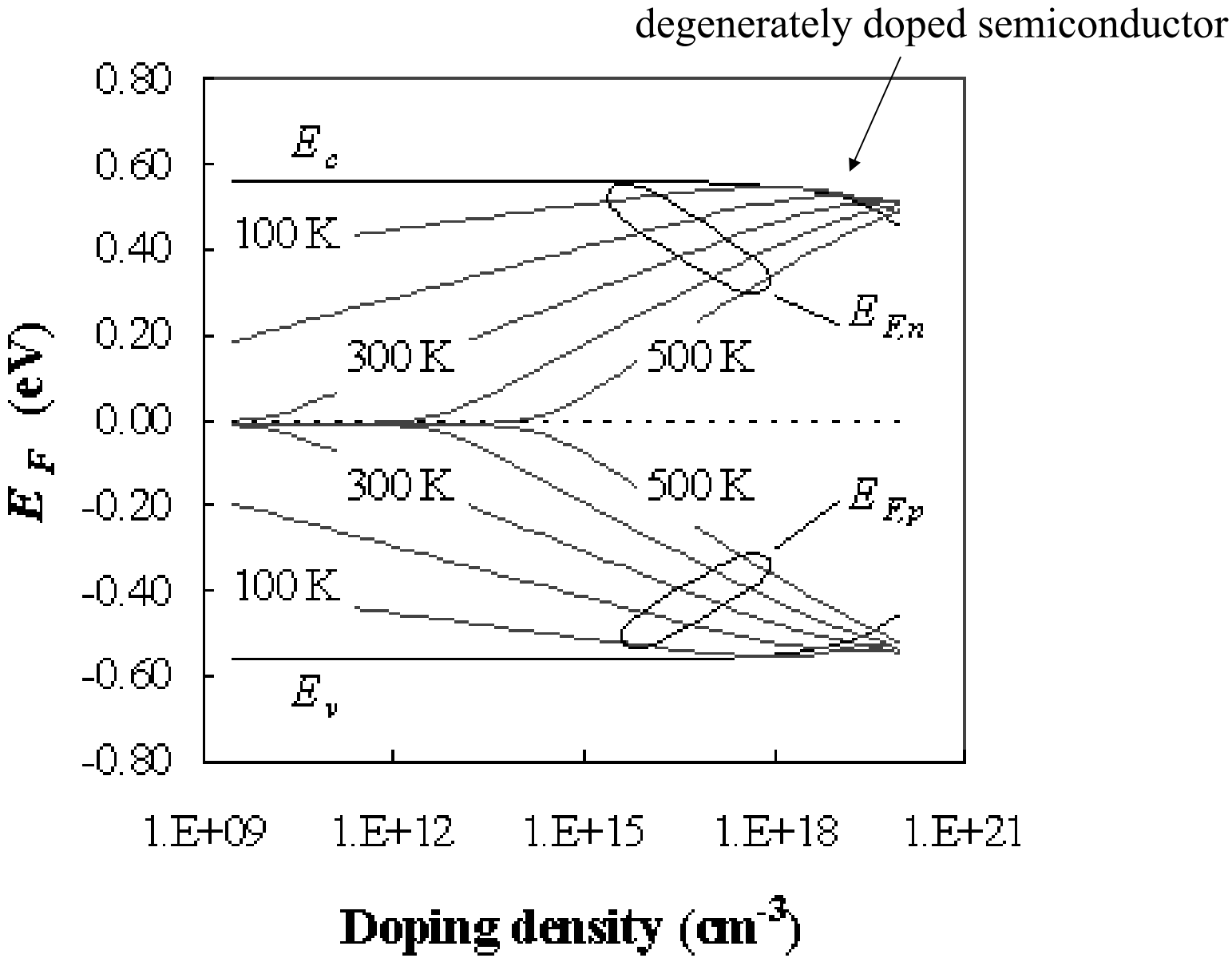
Once the Fermi energy is known, the carrier densities n and p can be calculated from the formulas, $n = N_c\left(\frac{T}{300}\right)^{3/2} \exp\left(\frac{E_F - E_c}{k_B T}\right)$ and $p = N_v\left(\frac{T}{300}\right)^{3/2} \exp\left(\frac{E_v - E_F}{k_B T}\right)$.

The intrinsic carrier density is $n_i = \sqrt{N_c\left(\frac{T}{300}\right)^{3/2} N_v\left(\frac{T}{300}\right)^{3/2}} \exp\left(\frac{-E_g}{2k_B T}\right)$.





http://lamp.tu-graz.ac.at/~hadley/psd/L4/eftplot.html


degenerately doped semiconductor
0.80
0.60
0.40
0.20
0.00
-0.20
-0.40
-0.60
-0.80
E_c
100 K
300 K
500 K
E_{Fn}
300 K
500 K
E_{Fp}
100 K
E_v
E_F (eV)
1.E+09
1.E+12
1.E+15
1.E+18
1.E+21
Doping density (cm^{-3})

Degenerate semiconductor

Heavily doped semiconductors are called degenerately doped

$N_D > 0.1\ N_c$ -> E_F in the conduction band

$N_A > 0.1\ N_v$ -> E_F in the valence band

Heavy doping narrows the band gap

The Boltzmann approximation is not valid

Degenerate semiconductors = metal

Carrier Transport

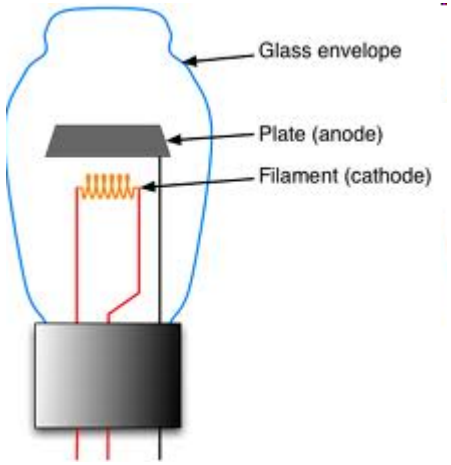
Ballistic transport
Drift
Diffusion
Generation and recombination
The continuity equation
High field effects

Ballistic transport

$$\vec{F} = m\vec{a} = -e\vec{E} = m\frac{d\vec{v}}{dt}$$

$$\vec{v} = \frac{-e\vec{E}t}{m} + \vec{v}_0$$

$$\vec{x} = \frac{-e\vec{E}t^2}{2m} + \vec{v}_0 t + \vec{x}_0$$



Electrons moving in an electric field follow parabolic trajectories like a ball in a gravitational field.

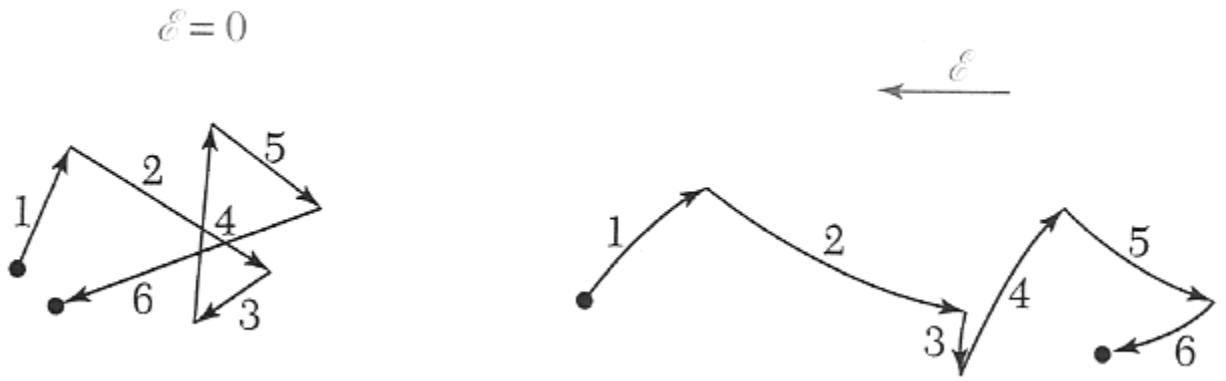
Drift

The electrons scatter and change direction after a time τ_{sc}.

Classical equipartition: $\frac{1}{2} m v_{th}^2 = \frac{3}{2} k_B T$

At 300 K, $v_{th} \sim 10^7$ cm/s.

mean free path: $\ell = v_{th} \tau_{sc} \sim 10$ nm ~ 200 atoms

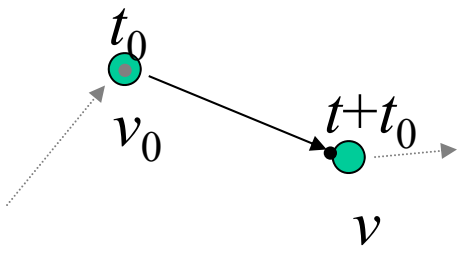


Drift (diffusive transport)

$$\vec{F} = -e\vec{E} = m^* \vec{a} = m^* \frac{d\vec{v}}{dt}$$

$$\vec{v} = \vec{v}_0 - \frac{e\vec{E}}{m^*}(t - t_0)$$

time between two collisions



$$\langle v_0 \rangle = 0 \qquad \langle t - t_0 \rangle = \tau_{sc}$$

$$\vec{v}_d = \frac{-e\vec{E}\tau_{sc}}{m^*} = \frac{-e\vec{E}\ell}{m^* v}$$

drift velocity: $\vec{v}_{d,n} = -\mu_n \vec{E}$ $\vec{v}_{d,p} = \mu_p \vec{E}$

Drift

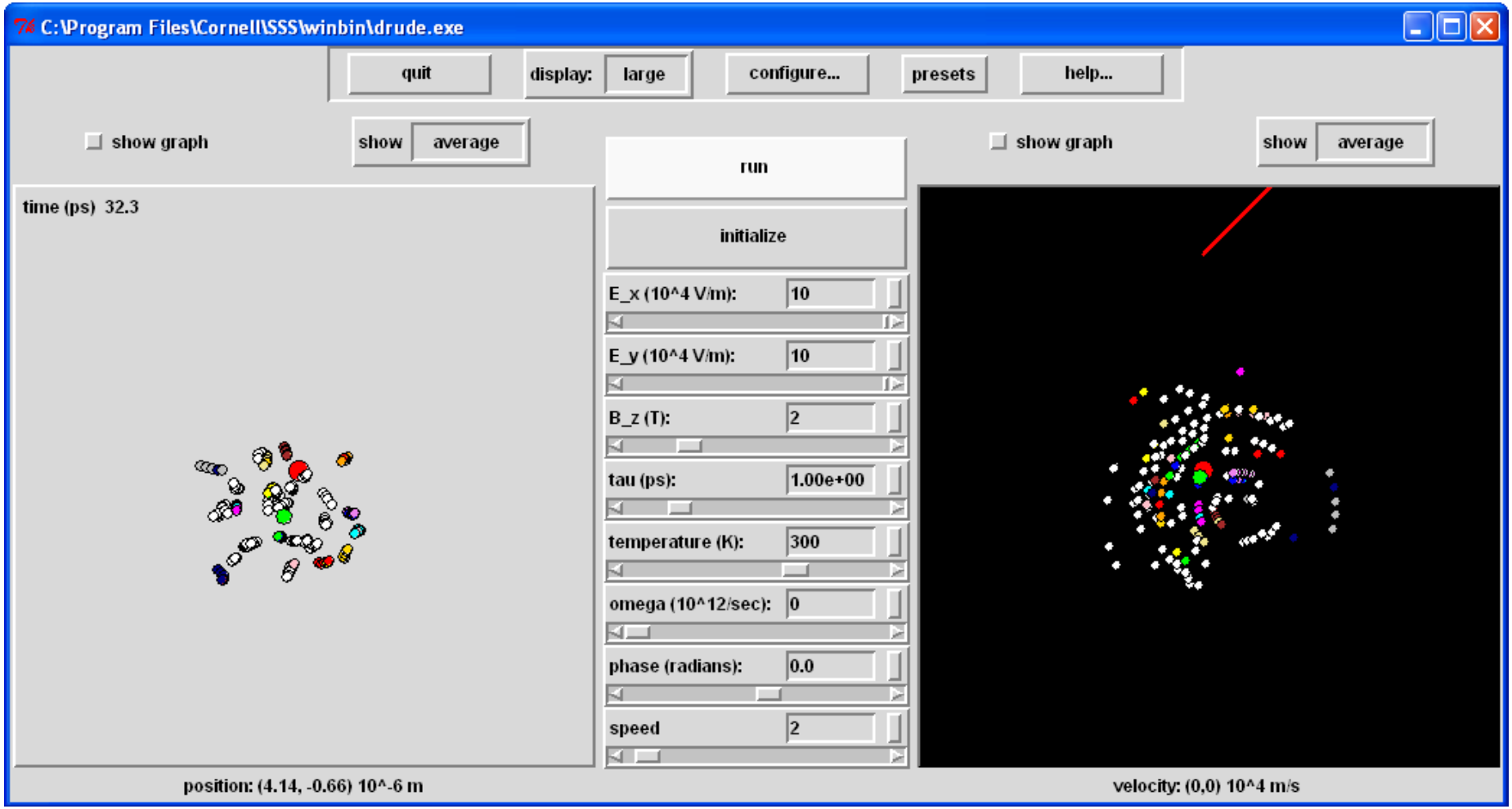
drift velocity: $\vec{v}_{d,n} = -\mu_n \vec{E}$ $\vec{v}_{d,p} = \mu_p \vec{E}$

$$\vec{j} = -ne\vec{v}_{d,n} + pe\vec{v}_{d,p} = \left(ne\mu_n + pe\mu_p\right)\vec{E} = \sigma\vec{E}$$

$$\mu = \frac{-e\tau_{sc}}{m^*} = \frac{-e\ell}{m^* v}$$

for Si: $\mu_n = 1500\ \text{cm}^2/\text{Vs}$
$\mu_p = 450\ \text{cm}^2/\text{Vs}$

For $E = 1000$ V/cm $v_d = 10^6$ cm/s


C:\Program Files\Cornell\SSS\winbin\drude.exe
quit
display:
large
configure...
presets
help...
show graph
show
average
run
initialize
time (ps) 32.3
E_x (10^4 V/m):
10
E_y (10^4 V/m):
10
B_z (T):
2
tau (ps):
1.00e+00
temperature (K):
300
omega (10^12/sec):
0
phase (radians):
0.0
speed
2
show graph
show
average
position: (4.14, -0.66) 10^-6 m
velocity: (0,0) 10^4 m/s